TRANSMITTAL FORM	Application Number	10/604,488
	Filing Date	07/25/2003
	First Named Inventor	David M. Dobuzinsky
	Group Art Unit	2814
	Examiner Name	Anh D. Mai
Total number of pages in this submission	Attorney Docket No.	FIS920030083US1

OIPE JC48 JAN 19 2005 PATENT & TRADEMARK OFFICE

ENCLOSURES

X	Fee Transmittal Form - Fee attached		Assignment Papers
X	Amendment		Declaration and Power of Attorney
	After Final ___ Declarations		Drawings
	Extension of Time Request		Petition
	Express Abandonment Request		Power of Attorney (Associate)
	Information Disclosure Statement		Terminal Disclaimer
	Certified Copy of Priority Documents		Appeal
	Response to Missing Parts - Incomplete		Status Letter
	Response to Missing Parts - Under 37 CFR 11.52 or 1.53		Other

The Filing Fee has been calculated as shown below:

For:	CLAIMS REMAINING AFTER AMENDMENT	HIGHEST NO. PAID FOR	Rate	Fee
Total Claims	10	20	$50..	0
Indep Claims	1	3	$200.	0
			Total	0

_X_ Please charge Deposit Account No. 09/0458 of International Business Machines Corporation in the amount of $0.00

_X_ The Commissioner is hereby authorized to charge any additional fees required herewith or credit any overpayment to Deposit Account No. 09/0458

Eric W. Petraske — Registration No. 28,459 — January 13, 2005 (Date)

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, U.S. Patent and Trademark Office, Alexandria, VA 22313-1450 on this date: January 13, 2005.

Eric W. Petraske

OIPE JC48
JAN 19 2005
PATENT & TRADEMARK OFFICE

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE	
In re application of: David M. Dobuzinsky	Filed: 07/25/2003 Examiner: Anh D. Mai
Serial No. 10/604,488	Group Art Unit: 2814
Title: DRAM Buried Strap Process With Silicon Carbide	Docket #: FIS920030083US1

AMENDMENT

Commissioner of Patents & Trademarks
Alexandria, VA 22313

Sir:

Responsive to the Office Action of 10/13/2004, please amend the above identified application as follows: